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Substitute	for form 1449A/PTO		Complete if Known			
			Application Number	To Be Assigned		
INFO	rmation [	DISCLOSURE	Filing Date	November 28, 2001		
STAT	EMENT BY	APPLICANT	First Named Inventor	Hatakeyama, et al.		
			Group Art Unit	To Be Assigned		
	(use as many sheet	s as necessary)	Examiner Name	To Be Assigned		
Sheet	1	of 1	Attorney Docket Number	KOJIM-436		

				U.S. F	PATENT DOCUM	MENTS						
	-	U.S. Pe	U.S. Petent Document  Kind Code <sup>2</sup> (if known)		Name of Petentee or Applicant of Cited Document		ublication of	Pages, Columns, Lines, Where Relevan Pesseges or Relevent Figures Appear				
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